

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Applicant: KIM et al. Examiner: Young, Christopher G.  
Serial No.: 10/827,513 Group Art Unit: 1756  
Filed: April 19, 2004  
For: **STENCIL MASK HAVING MAIN AND AUXILIARY  
STRUT METHOD OF FORMING THE SAME**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**RESPONSE TO RESTRICTION REQUIREMENT**


Sir:

In response to the Office Action dated August 10, 2007, Applicants provisionally elect the claims of Group I (i.e., claims 1-13 and 50-51).

While the device of Group I and the method of Group II may be distinct as set forth by the Examiner, Applicants believe that simultaneous examination will not present an undue burden. For example, the claims of Group I are drawn to stencil masks and the claims of Group II are drawn to methods of making stencil masks. The subject matter of Group I and Group II can be found in class 430. Under such circumstances, the Examiner is encouraged to maintain the claims of Groups I and II in the same application. See, MPEP § 803.

Early and favorable consideration of the application is earnestly solicited.

Respectfully submitted,

  
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